



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 9938
Hiroshi TAKANASHI et al. : Docket No. 2001_0476
Serial No. 09/838,118 ✓ : Group Art Unit 1752
Filed April 20, 2001 : Examiner S. Lee

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NEGATIVE-WORKING PHOTSENSITIVE
RESIN COMPOSITION AND
PHOTSENSITIVE RESIN PLATE
USING THE SAME

RESPONSE UNDER 37. CFR 1.116
EXPEDITED PROCEDURE
EXAMINING GROUP 1752

RESPONSE UNDER 37 C.F.R. 1.116

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Final Rejection dated March 20, 2003, the period for response having been extended for three months by the attached petition, please amend the present application as follows: